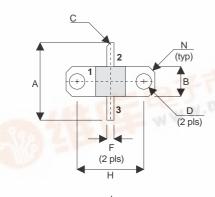
**TetraFET** 

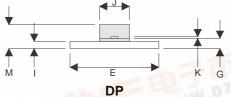


# **D5013UK**

# ROHS COMPLIANT METAL GATE RF SILICON FET

### **MECHANICAL DATA**





PIN<sub>2</sub>

**DRAIN** 

PIN 1 SOURCE

PIN 3 GATE

DIM	mm	Tol.	Inches	Tol.
Α	16.51	0.25	0.650	0.010
В	6.35	0.13	0.250	0.005
С	45°	5°	45°	5°
D	3.30	0.13	0.130	0.005
Е	18.92	0.08	0.745	0.003
F	1.52	0.13	0.060	0.005
G	2.16	0.13	0.085	0.005
Н	14.22	0.08	0.560	0.003
	1.52	0.13	0.060	0.005
J	6.35	0.13	0.250	0.005
K	0.13	0.03	0.005	0.001
M	5.08	0.51	0.200	0.020
N	1.27 x 45°	0.13	0.050 x 45°	0.005

# GOLD METALLISED MULTI-PURPOSE SILICON DMOS RF FET 20W - 50V - 500MHz SINGLE ENDED

# **FEATURES**

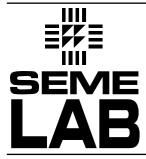
- SIMPLIFIED AMPLIFIER DESIGN
- SUITABLE FOR BROAD BAND APPLICATIONS
- LOW C<sub>rss</sub>
- USEFUL PO AT 1GHz
- LOW NOISE
- HIGH GAIN 13 dB MINIMUM

# **APPLICATIONS**

 HF/VHF/UHF COMMUNICATIONS from 1 MHz to 1 GHz

# ABSOLUTE MAXIMUM RATINGS (T<sub>case</sub> = 25°C unless otherwise stated)

$\overline{P_D}$	Power Dissipation	50W
BV <sub>DSS</sub>	Drain - Source Breakdown Voltage	125V
BV <sub>GSS</sub>	Gate – Source Breakdown Voltage	±20V
I <sub>D(sat)</sub>	Drain Current	3A
$T_{stg}$	Storage Temperature	–65 to 150°C
The space of the s	Maximum Operating Junction Temperature	200°C



# **D5013UK**

# **ELECTRICAL CHARACTERISTICS** (T<sub>case</sub> = 25°C unless otherwise stated)

Parameter		Test Conditions		Min.	Тур.	Max.	Unit
D\/	Drain-Source	V0	L = 100mΛ	125			V
$BV_{DSS}$	Breakdown Voltage	$V_{GS} = 0$	I <sub>D</sub> = 100mA	125			V
I <sub>DSS</sub>	Zero Gate Voltage	\/ _ F0\/	V 0			1	mA
	Drain Current	$V_{DS} = 50V$	$V_{GS} = 0$			ı	IIIA
I <sub>GSS</sub>	Gate Leakage Current	V <sub>GS</sub> = 20V	V <sub>DS</sub> = 0			1	μΑ
V <sub>GS(th)</sub>	Gate Threshold Voltage*	I <sub>D</sub> = 10mA	$V_{DS} = V_{GS}$	1		7	V
9 <sub>fs</sub>	Forward Transconductance*	V <sub>DS</sub> = 10V	I <sub>D</sub> = 0.5A	0.8			S
G <sub>PS</sub>	Common Source Power Gain	P <sub>O</sub> = 20W		13			dB
η	Drain Efficiency	$V_{DS} = 50V$	I <sub>DQ</sub> = 0.1A	50			%
VSWR	Load Mismatch Tolerance	f = 500MHz		20:1			_
C <sub>iss</sub>	Input Capacitance	$V_{DS} = 50V$	$V_{GS} = -5V f = 1MHz$			60	pF
C <sub>oss</sub>	Output Capacitance	V <sub>DS</sub> = 50V	$V_{GS} = 0$ $f = 1MHz$			25	pF
C <sub>rss</sub>	Reverse Transfer Capacitance	V <sub>DS</sub> = 50V	$V_{GS} = 0$ $f = 1MHz$			1.5	pF

<sup>\*</sup> Pulse Test: Pulse Duration = 300  $\mu s$ , Duty Cycle  $\leq$  2%

# **HAZARDOUS MATERIAL WARNING**

The ceramic portion of the device between leads and metal flange is beryllium oxide. Beryllium oxide dust is highly toxic and care must be taken during handling and mounting to avoid damage to this area.

### THESE DEVICES MUST NEVER BE THROWN AWAY WITH GENERAL INDUSTRIAL OR DOMESTIC WASTE.

# THERMAL DATA

R <sub>THj-case</sub>	Thermal Resistance Junction – Case	Max. 3.5°C / W
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